

Notice of References Cited

Application/Control No.

10/537,497

Applicant(s)/Patent Under
Reexamination
NAKANISHI ET AL.

Examiner

RYAN OCHYLSKI

Art Unit

4151

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U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-			
	B	US-			
	C	US-			
	D	US-			
	E	US-			
	F	US-			
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FOREIGN PATENT DOCUMENTS

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NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	AUTHORS: Suzuki, Masao, Kasai, Hitoshi, Miura, Hirohiko, Okada, Shuji, Oikawa, Hidetoshi, Nihira, Takayasu; Fukuro, Hiroyoshi; Nakanishi, Hachiro; TITLE: Preparation of poly(amic acid) nanoparticles using the reprecipitation method and their imidization; PUBLISHER: Kobunshi Gakka; SOURCE: Kobunshi Ronbunshu (2002), 59(10), 637-641
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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
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